

Method for Forming Three-Dimensional Structures on a Substrate

ABSTRACT OF THE DISCLOSURE

A method of forming a resist layer on a non-planar surface of a substrate includes placing the non-planar surface into an electrophoretic resist. While the non-planar surface is in the electrophoretic resist, an electrical voltage is applied between the substrate and the electrophoretic resist. The non-planar surface can then be removed from the electrophoretic resist.